IN THE CLAIMS

This listing of claims replaces all prior listings

Listing of Claims:

1. (Currently Amended) Method of manufacturing a diffusing reflector comprising the processes of:

preparing ~~for~~ a substrate;

forming a first resin film having photosensitivity on said substrate;

providing gathering of pillar-shaped bodies isolated from each other through patterning of said resin film with ~~the~~ photolithography;

~~forming uneven surface layer having the maximum inclination angle of under 12^0 by gently~~ deforming gently ~~individual~~ said pillar-shaped bodies through ~~the~~ a reflow;

forming an uneven surface layer having the maximum inclination angle of under 12^0 by coating said gently deformed pillar-shaped bodies and covering open flat spaces located between said isolated pillar-shaped bodies with a second resin, thereby minimizing an occurrence of a flat surface area on said substrate; and

forming a metal film on ~~gathering of~~ said ~~gently deformed~~ uneven surface layer.

2. (Original) Method of manufacturing a diffusing reflector as claimed in claim 1, wherein said maximum inclination angle is about 10^0.

3. (Cancelled)

4. (Currently Amended) Method of manufacturing a diffusing reflector as claimed in claim 1, wherein said reflow process is ~~the~~ a heat treatment under the temperature of about 220 ^{0}C.

5. (Currently Amended) Method of manufacturing a diffusing reflector as claimed in claim 1, wherein gathering of polygonal pillar-shaped bodies isolated each other by the divided patterning of said first resin film by said photolithography is provided.

6. (Currently Amended) Method of manufacturing a diffusing reflector as claimed in claim 5, wherein said first resin film is patterned by the divided patterning means so that size of gap between said polygonal pillar-shaped bodies isolated each other is almost equal to ~~the~~ a minimum resolution of photolithography.